

Title (en)

Global point spreading function in multi-beam patterning

Title (de)

Allgemeine Punktverbreitungsfunktion bei Mehrstrahlenmusterung

Title (fr)

Fonction de dispersion globale du point dans la formation de motifs à plusieurs faisceaux

Publication

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Application

EP 10450020 A 20100217

Priority

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Abstract (en)

[origin: EP2228817A2] In a particle multi-beam structuring apparatus (1) for forming a pattern on a surface of a target (13) by means of a beam of electrically charged particles, during a sequence of exposure steps said particle beam (1b) is produced, directed through a pattern definition means (3) producing a patterned particle beam (pb) composed of a multitude of beamlets, and projected by means of an optical column (4) comprising at least one controllable deflection means (12) onto said target surface to form, at a nominal location on the target (13), a beam image comprising the image of defining structures in the pattern definition means (3), wherein said beam image is moved to different locations, respectively, by changing the nominal location of the beam image with respect to the target (13) between exposure steps. By means of said controllable deflection means (12) the actual location of the beam image is varied within each exposure steps around the nominal location, through a set of locations realizing a distribution of locations within the image plane around a mean location coinciding with the nominal location, thus introducing an additional blur which is homogenous over the entire beam image.

IPC 8 full level

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